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CLAIM SET AS AMENDED

1. (Currently Amended) A solid-state imaging device equipped with plural unit

pixels each of which includes a photo-diode and a photo-detector on a substrate, the photo-

diode comprising a charge generating region to generate charges upon light irradiation, the

photo-detector comprising a charge accumulation region to accumulate the charges

transferred from the charge generating region and generating a signal potential that changes

in accordance with the amount of the charges in the charge accumulation region, the solid-

state imaging device comprising:

a charge transfer region provided between the charge generating region and the

charge accumulation region of the pixel, the charge transfer region forming a first potential

barrier to the charges in the charge generating region, the first potential barrier being

removable according to the an applied voltage to the photo-detector.

2. (Currently Amended) The solid-state imaging device according to claim 1, further

comprising a first charge eliminating region formed between the substrate and the charge

accumulating accumulation region, the charges in the charge accumulating accumulation

region being eliminated to the substrate via said first charge eliminating region when a

certain voltage is applied to the photo-detector.

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3. (Currently Amended) The solid-state imaging device according to claim 1, further

comprising:

a second charge eliminating region formed near the charge generating region; and

a region, provided between the charge generating region and the second charge

eliminating region, that forms a second potential barrier to the charges in the charge

accumulating accumulation region, the second potential barrier being lower than the first

potential barrier such that the charges in the charge eliminating region-is are overflowed to a

surface side, opposite to the substrate, via the second charge eliminating region.

4. (Currently Amended) The solid-state imaging device according to claim 3 claim

1, wherein the second potential barrier being is removable according to the an applied

voltage to the second charge eliminating region.

5. (Currently Amended) The solid-state imaging device according to claim 1,

wherein the charge generating region has one conductive type, same as the substrate, and the

photo-diode comprises a first region with opposite conductive type that contacts the charge

generating region, and

wherein the photo-detector is a field effect transistor and comprises:

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a channel region formed on the surfaces of the charge accumulating accumulation

region with one conductive type and the charge transfer region with opposite conductive

type;

a gate electrode formed on a gate insulation layer that is formed on the channel

region;

a source region having opposite conductive type, the source region near the charge

accumulating accumulation region being connected to the channel region; and

a drain region with opposite conductive type that is apart from the source region by

the channel region, the signal potential being generated in the source region.

6. (Original) The solid-state imaging device according to claim 5, wherein the plural

pixels are arranged in first and second directions to form a matrix, the source regions of the

pixels along the first direction being connected to one another, the gate electrodes of the

pixel along the second direction being connected to one another, and the drain regions of all

pixels being common.

7. (Currently Amended) The solid-state imaging device according to claim 6, further

comprising:

a switch circuit capable of electrically connecting and disconnecting the source

region and the drain region of the pixel; and

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a first charge eliminating region formed between the substrate and the charge

accumulating accumulation region, the charges in the charge accumulating accumulation

region being eliminated to the substrate via the first charge eliminating region when the

potentials of the charge accumulating accumulation region and the charge transfer region are

increased by boosting up the a voltage to the gate electrode,

wherein the voltage to the gate electrode is boosted by applying a voltage to the

source and drain regions simultaneously while keeping the gate electrode at a high

impedance state.

8. (Currently Amended) The solid-state imaging device according to claim 6, further

comprising:

a second charge eliminating region formed near the charge generating region,

wherein the second charge eliminating region having has one conductive type; and

a second region with opposite conductive type, provided between the charge

generating region and the second charge eliminating region, the second region forming a

second potential barrier to the charges in the charge accumulating accumulation region, the

second potential barrier being lower than the first potential barrier such that the charges in

the charge eliminating region-is are overflowed to a surface side, opposite to the substrate,

via the second charge eliminating region.

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9. (Currently Amended) The solid-state imaging device according to claim 8,

wherein the second potential barrier-being is removable according to the an applied voltage

to the second charge eliminating region.

10. (Withdrawn-Currently Amended) A method of driving the solid-state imaging

device according to claim 2, comprising the steps of:

(a) removing the first potential barrier in the charge transfer region to transfer the

charged from the charge generating region to the charge accumulation region;

(b) eliminating the charges in the charge accumulating-accumulation region to the

substrate through the first charge eliminating region;

(c) storing the photo-generated charges in the charge generating region for a

predetermined period;

(d) removing the first potential barrier to transfer the charges from the charge

generating region to the charge-accumulating accumulation region;

(e) detecting the signal potential of the photo-detector as the first signal potential;

(f) eliminating the charges in the charge-accumulating accumulation region to the

substrate through the first charge eliminating region;

(g) detecting the signal potential of the photo-detector as the second signal potential;

and

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(h) subtracting the second signal potential from the first signal potential to output an

image signal.

11. (Withdrawn) The method according to claim 10, wherein the steps (a) to (d) are

carried out for all pixels at the same time, and the steps (e) to (h) are carried out for the pixels

on a selected line.

12. (Withdrawn) The method according to claim 10, wherein the steps (c) and (d)

are repeated in this order.

13. (Withdrawn-Currently Amended) A method of driving the solid-state imaging

device according to claim 2, the solid-state imaging device comprising:

a second charge eliminating region formed near the charge generating region; and

a region, provided between the charge generating region and the second charge

eliminating region, that forms a second potential barrier to the charges in the charge

accumulating accumulation region, the second potential barrier being removable according

to the an applied voltage to the second charge eliminating region,

the method comprising the steps of:

(a) removing the first potential barrier to transfer the charges from the charge

generating region to the charge accumulating accumulation region;

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(b) detecting the signal potential of the photo-detector as the first signal potential;

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(c) eliminating the charges in the charge accumulating accumulation region to the

substrate through the first charge eliminating region;

(d) detecting the signal potential of the photo-detector as the second signal potential;

(e) subtracting the second signal potential from the first signal potential to output an

image signal; and

(f) removing the second potential barrier of all pixels to eliminating the charges in

the charge generating region to the second charge eliminating region while carrying out the

steps (b) to (e).

14. (New) The solid-state imaging device according to claim 1, further comprising

a second charge eliminating region formed near the charge generating region.

wherein the second charge eliminating region is a p + type impurity region formed on

an upper surface of an n + type impurity region in the photo diode.

15. (New) The solid-state imaging device according to claim 3, wherein the region is

a small gap bounded on one lateral side by the charge generating region, and bounded on an

opposite side by an n + type impurity region